NumericalAnalysis of a Thermal Plasma Scrubber for CF<sub>4</sub> Decomposition

Juyoung Ko  $^{1}\!,$  Sooseok Choi  $^{1}\!,$  and Tae Hee Kim  $^{2}$ 

<sup>1</sup>Department of Nuclear and Energy Engineering, Jeju National University, Korea, Republic of <sup>2</sup>Institute for Nuclear Science and Technology, Jeju National University, Korea, Republic of

Perfluorocompound (PFC) gases emitted in semiconductor and displaymanufacturing processes have a very long life time in theatmosphere and a high global warming potential (GWP) which is thousands oftimes higher than those of carbon dioxide and hydrocarbons. PFCs decompositionrequire a high temperature environment due to their high chemical stability. Therefore, DC non-transferred thermal plasma scrubbers were commercialized to the semiconductor process as post-treatment.

Among PFCs,  $CF_4$  is the most non-degradable greenhouse gas which is decomposed in a hightemperature above 2,300 K. In order to propose more efficient decompositionenvironment, in this work, the numerical analysis for  $CF_4$  exhaustgas decomposition in the thermal plasma reactor was carried out in variousdesign variables. The decomposition reaction was applied include water, since the chemical reaction with water molecules drops the decomposition temperature about 1,500 K through the reaction with H<sub>2</sub>. The calculated results were verified by comparing measured arc voltage and input power as experimental data.

As severaldesign variables, the injected angles of  $CF_4$  gas to the reactor werecontrolled to  $30^\circ, 45^\circ, 60^\circ, 75^\circ$ , and  $90^\circ$ . The injected location of  $CF_4$  gas was applied to 50, 80, 110, and 200 mm from the torch exit. In the numerical analysis result, vertical injection of  $CF_4$  gas at  $90^\circ$  creates the improved mixing  $CF_4$  gas with the thermal plasma flame. In addition, the bottleneck shaped reactor extended the high temperature region due to a vortexgeneration by strong turbulence. It is expected that the decomposition rate isimproved as increasing the residence time of  $CF_4$  at the hightemperature region over 1,500 K. Furthermore, the chemical reactions for the  $CF_4$  decomposition was contained to the numerical analysis as an enhanced thermal plasma simulation. It offers not only thermal environment expectation alsodecomposed chemicals information. As a result, the optimal design condition isproposed to expect the higher decomposition rate.